

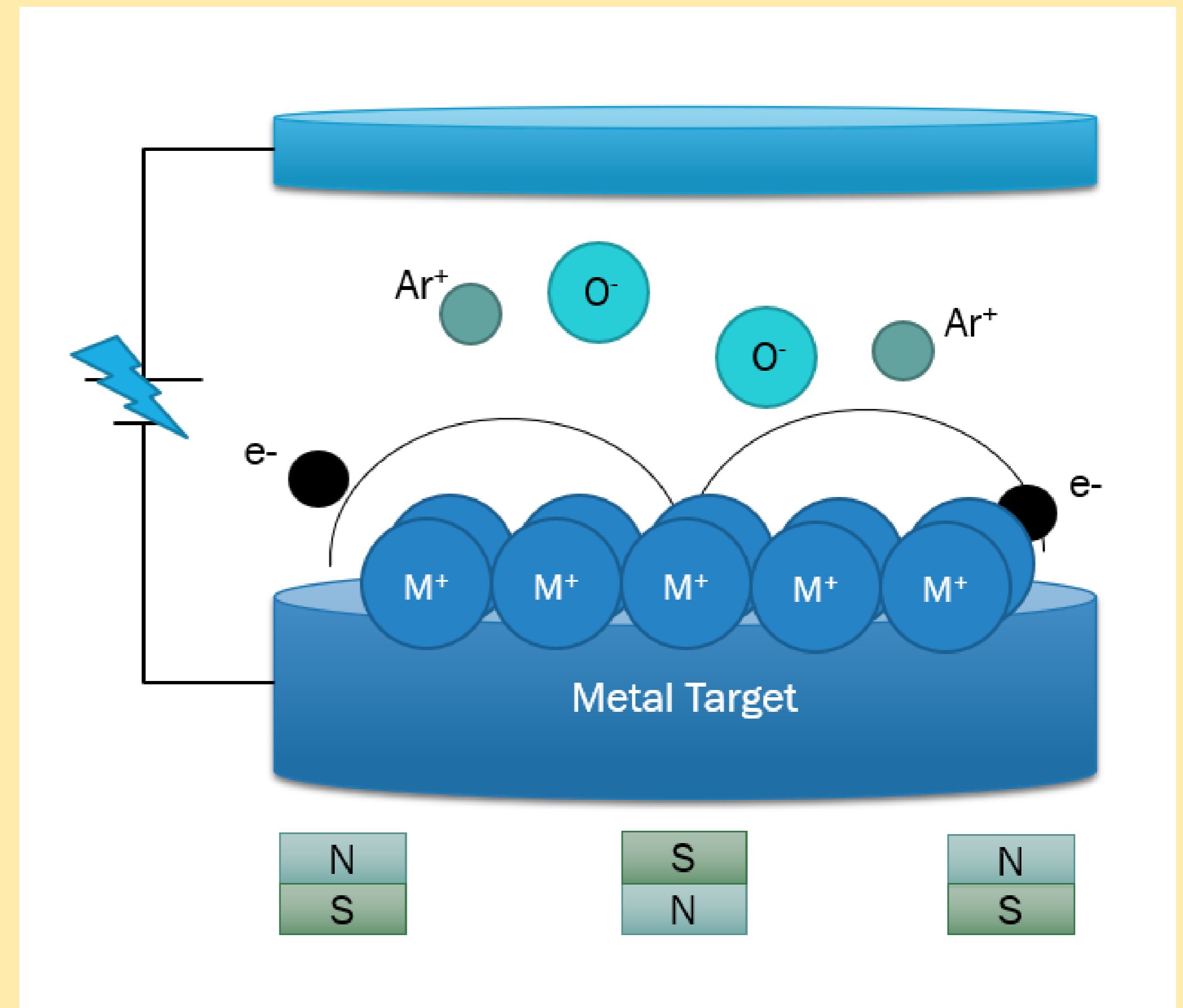
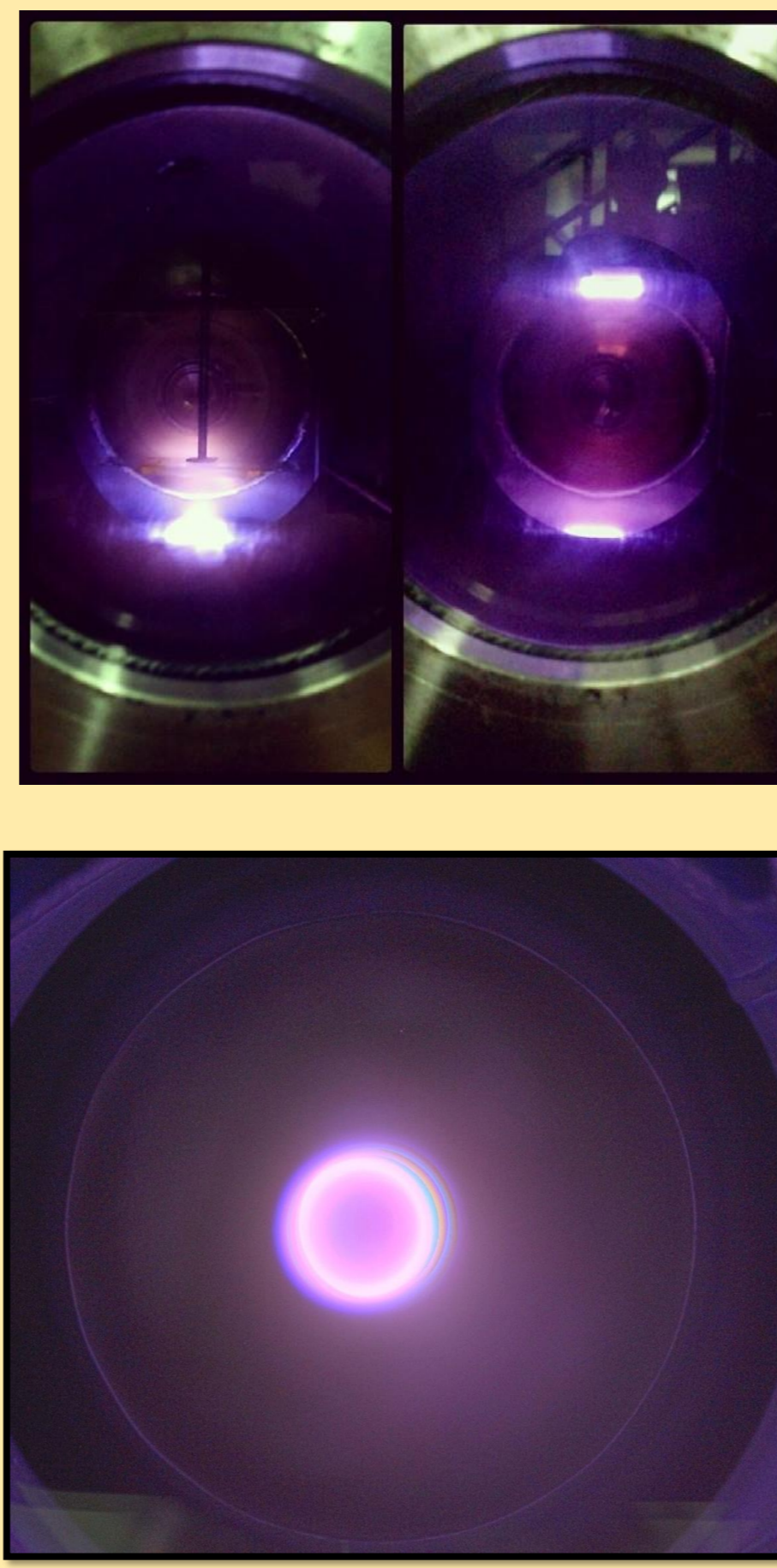
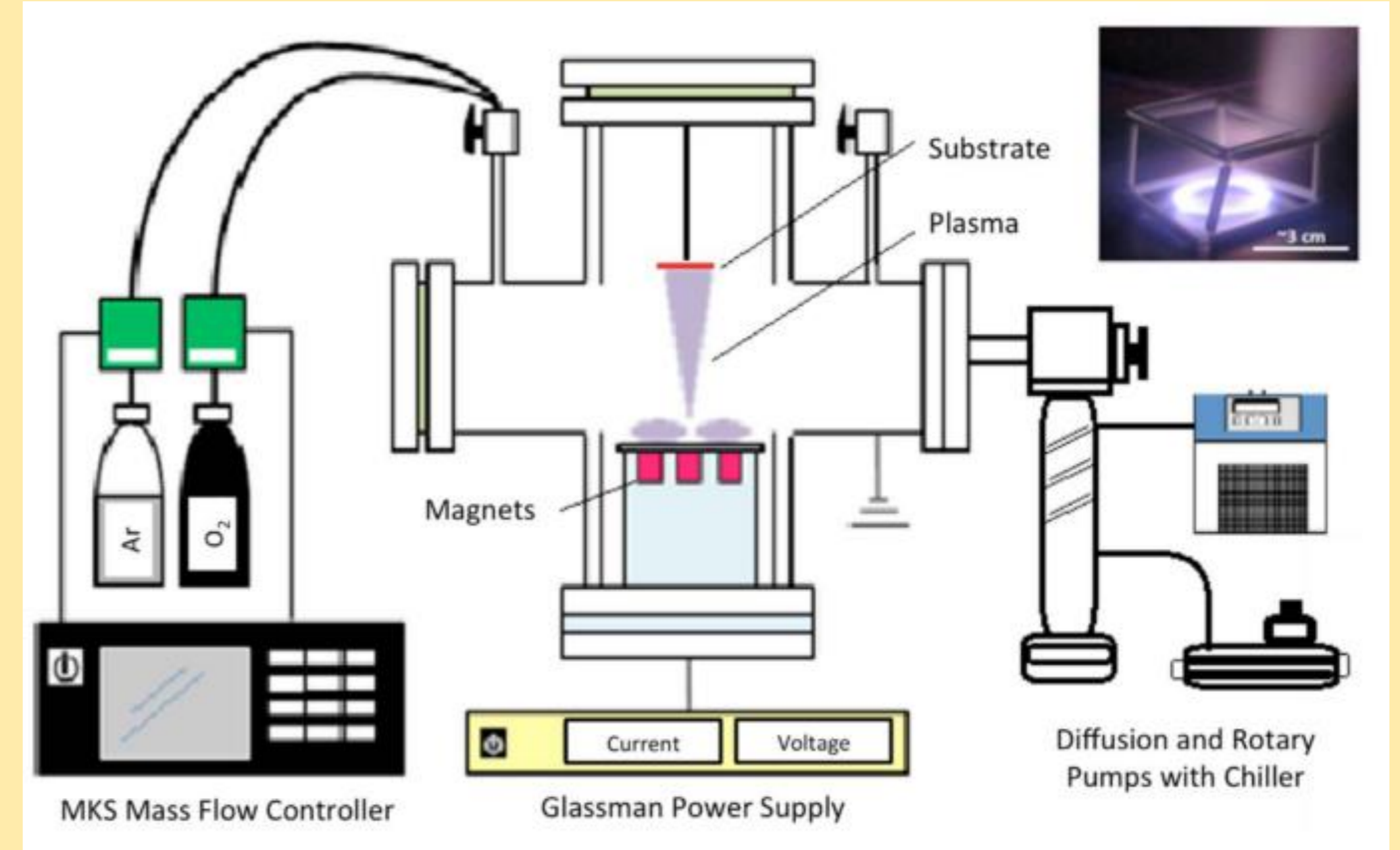


Magnetron sputtered and microwave-assisted thin film deposition

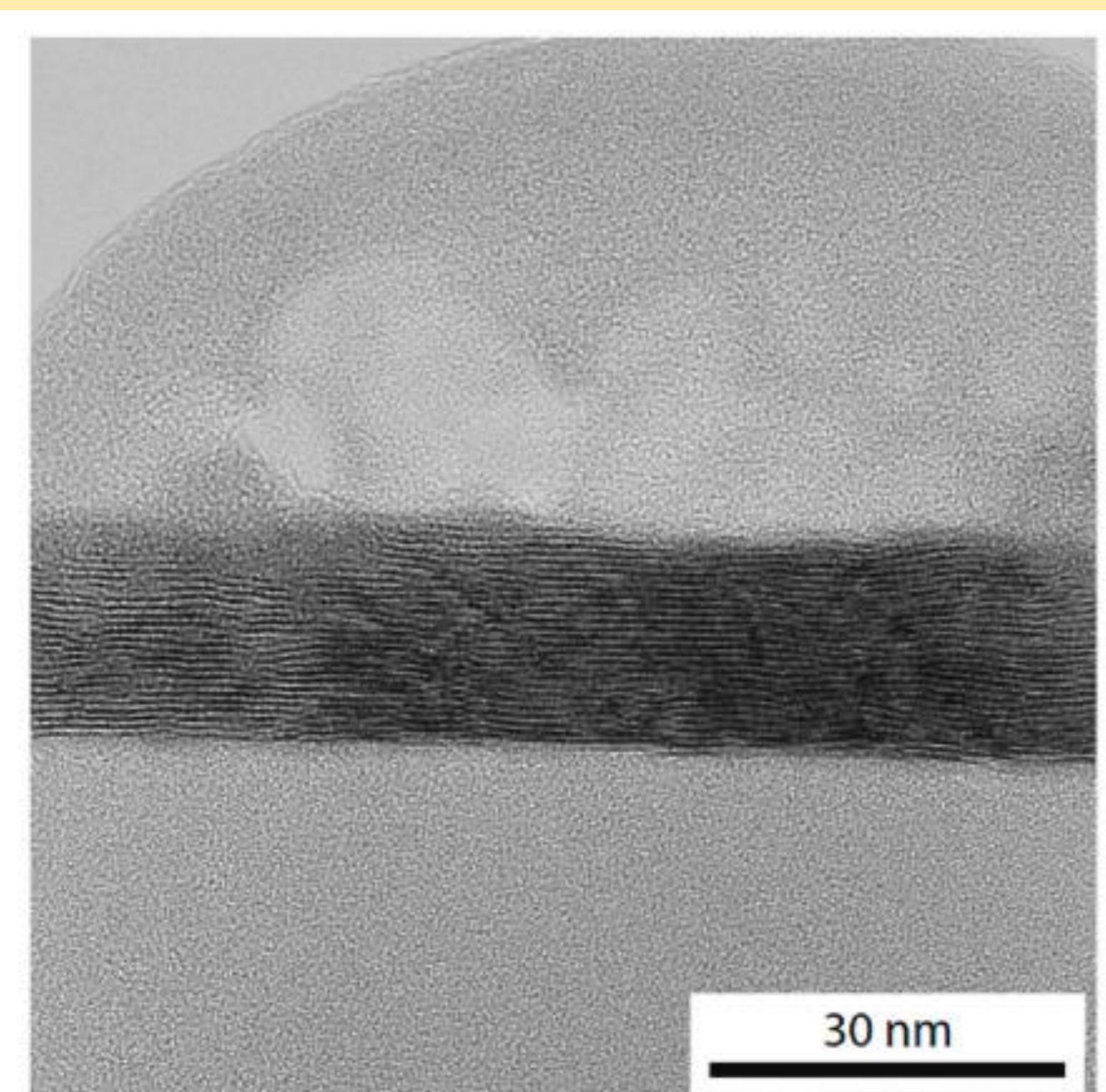
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Magnetron Sputtering

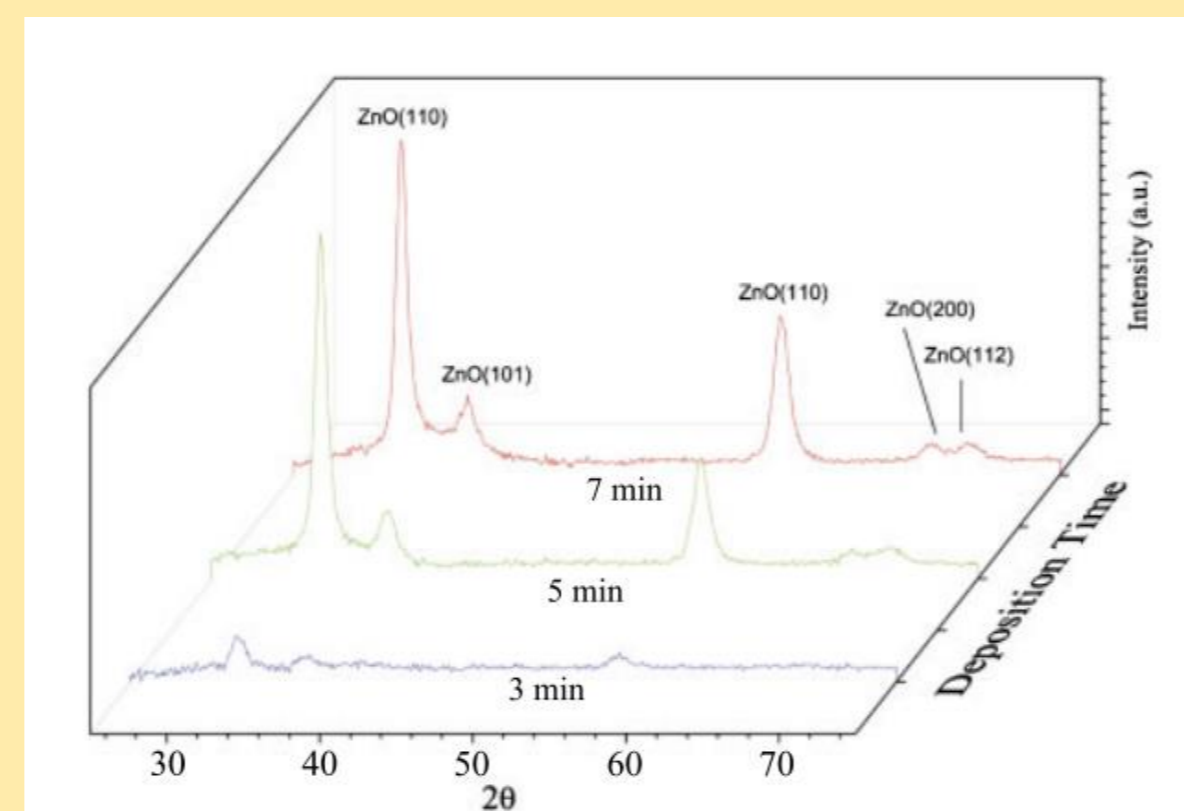
- A process where energetic ions (example Ar^+) bombard the target material
- The sputtered material reacts with reactive gases (example O^-) to form a thin film on the substrate
- The thin films can be used for various applications



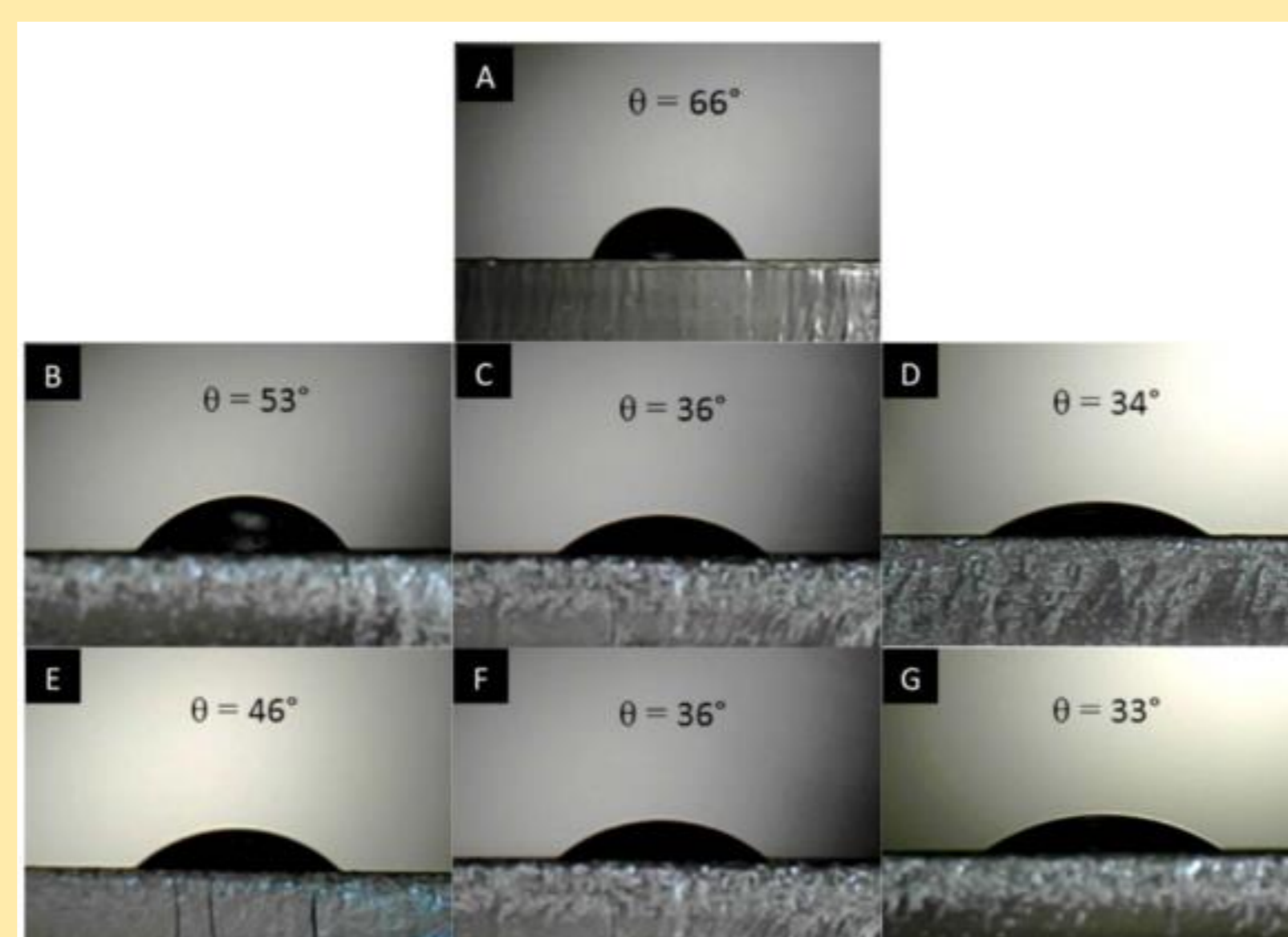
Applications



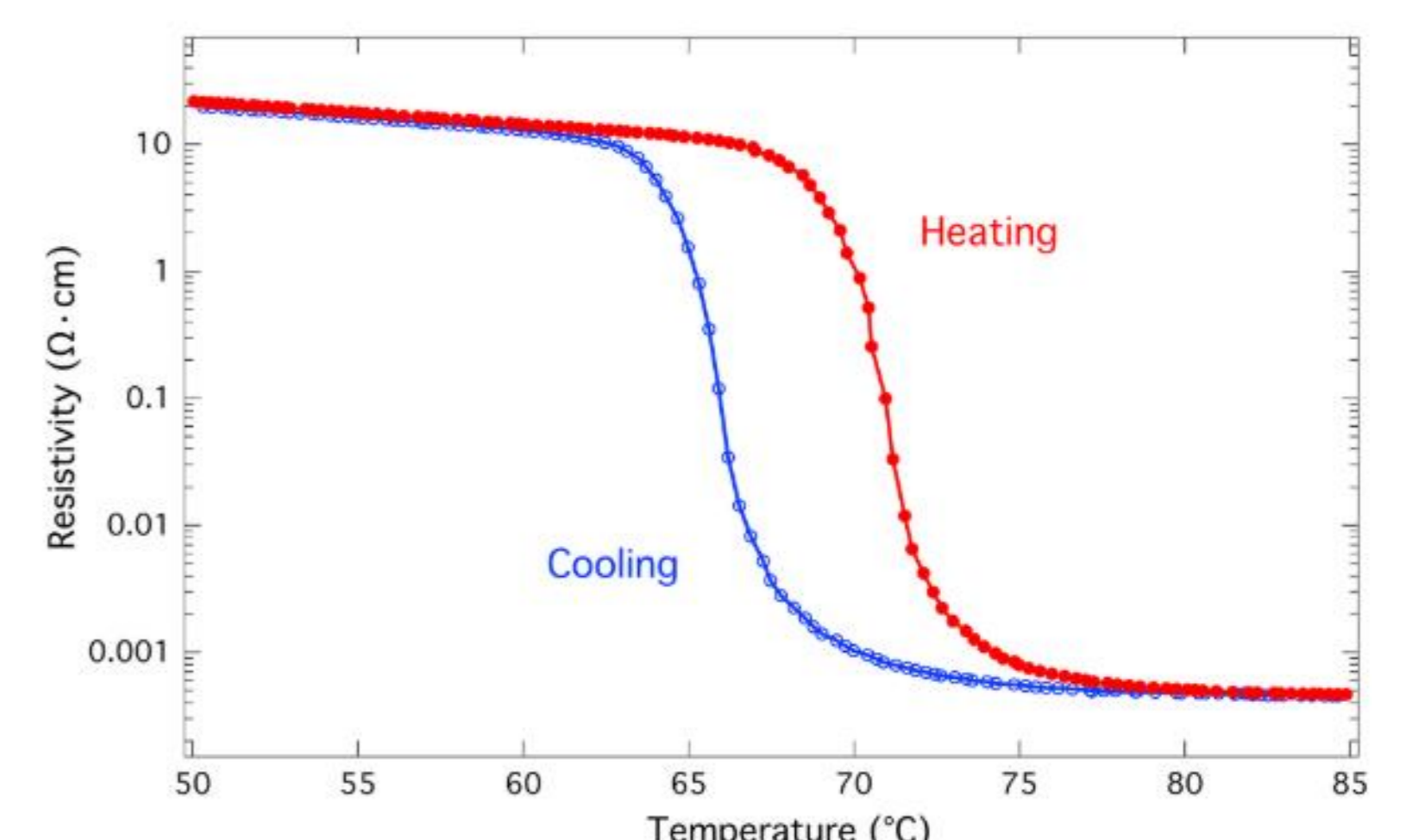
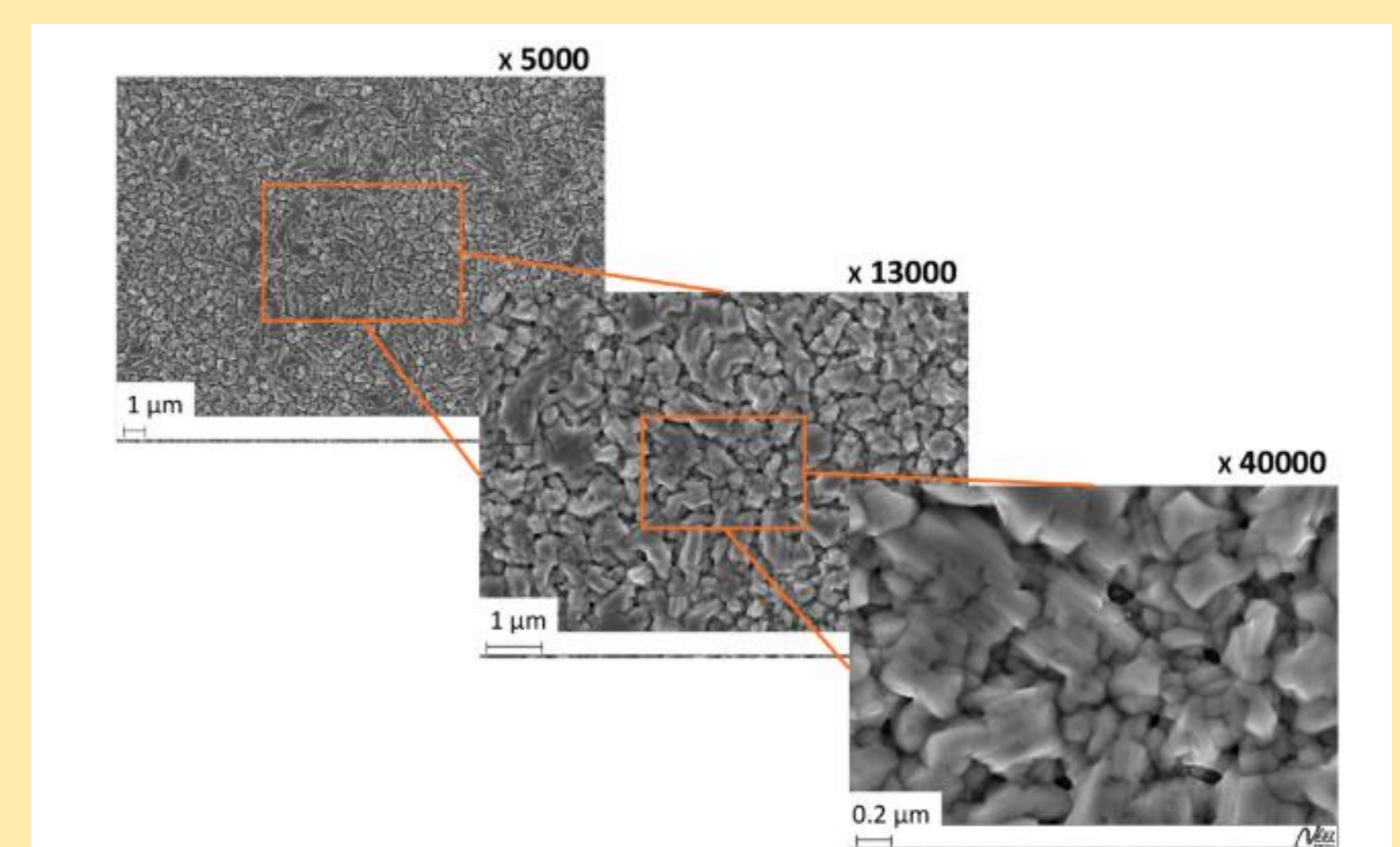
2D layered WS_2



Transparent conducting ZnO



Photocatalytic TiO_2



Metal-Insulator Transitioning VO_2